

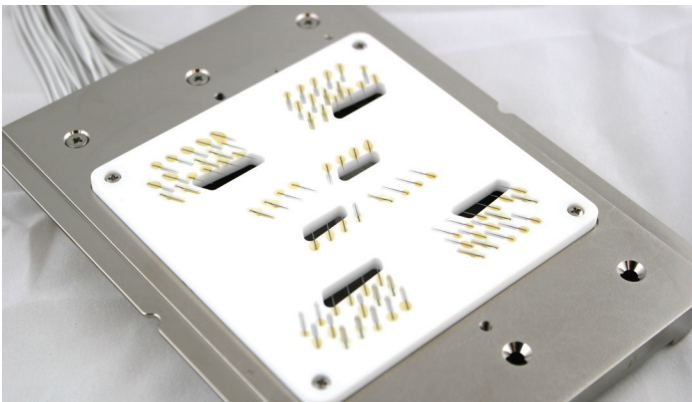
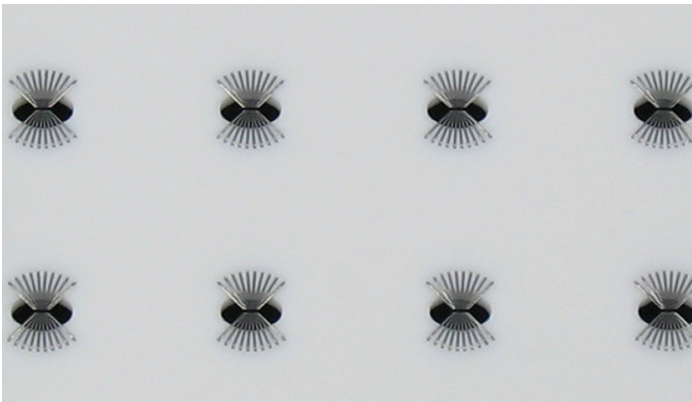
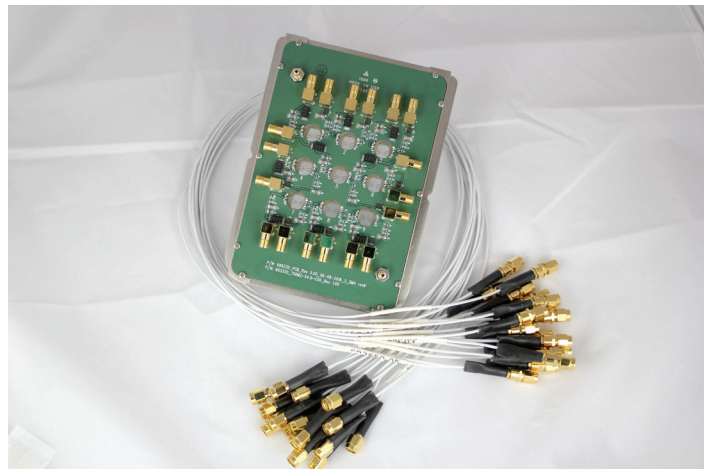
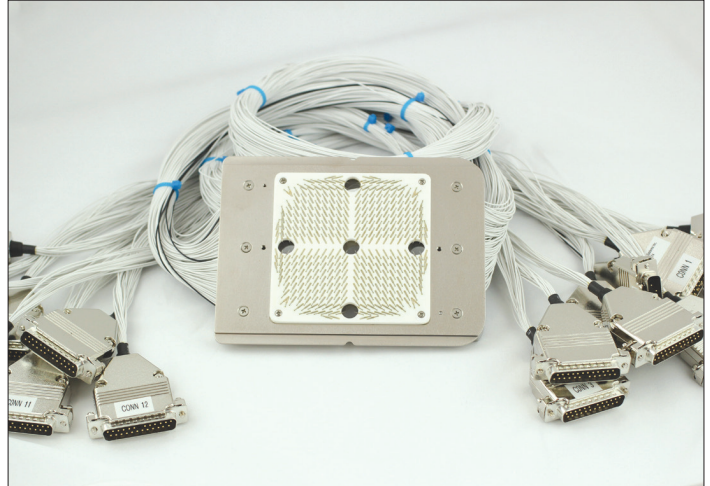
HIGH-DENSITY MULTI-SITE TESTING

T90 SERIES

Multi-site modeling and Characterization,
Wafer Level Reliability, and Burn-in

T90 Series probe cards are compatible with industry-standard 4.5" rails, but can be configured with up to 500 probes for dense multi-site wafer level reliability testing. With an effective operating temperature range from -65° to 300° [optional 400°C], T90 probe cards can deliver dependable and accurate low leakage test data.

The T90 probe card is a durable, reliable, and rugged solution for high density wafer level reliability testing, and at the same time are compact and easy to use with a variety of testing platforms.



HIGH-DENSITY
MULTI-SITE
TESTING IN A
CONVENIENT
4.5" FORMAT